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(12) **United States Design Patent**
Biedrzycki

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(54) **NOVELTY MASK**

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(**) **Term:** **14 Years**

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(51) **LOC (7) Cl.** **02-03**

(52) **U.S. Cl.** **D2/869**

(58) **Field of Search** D2/865, 869, 870, D2/871, 872; 2/171, 171.01, 181, 182.1, 195.1, 200.1, 200.2; D1/199, 106

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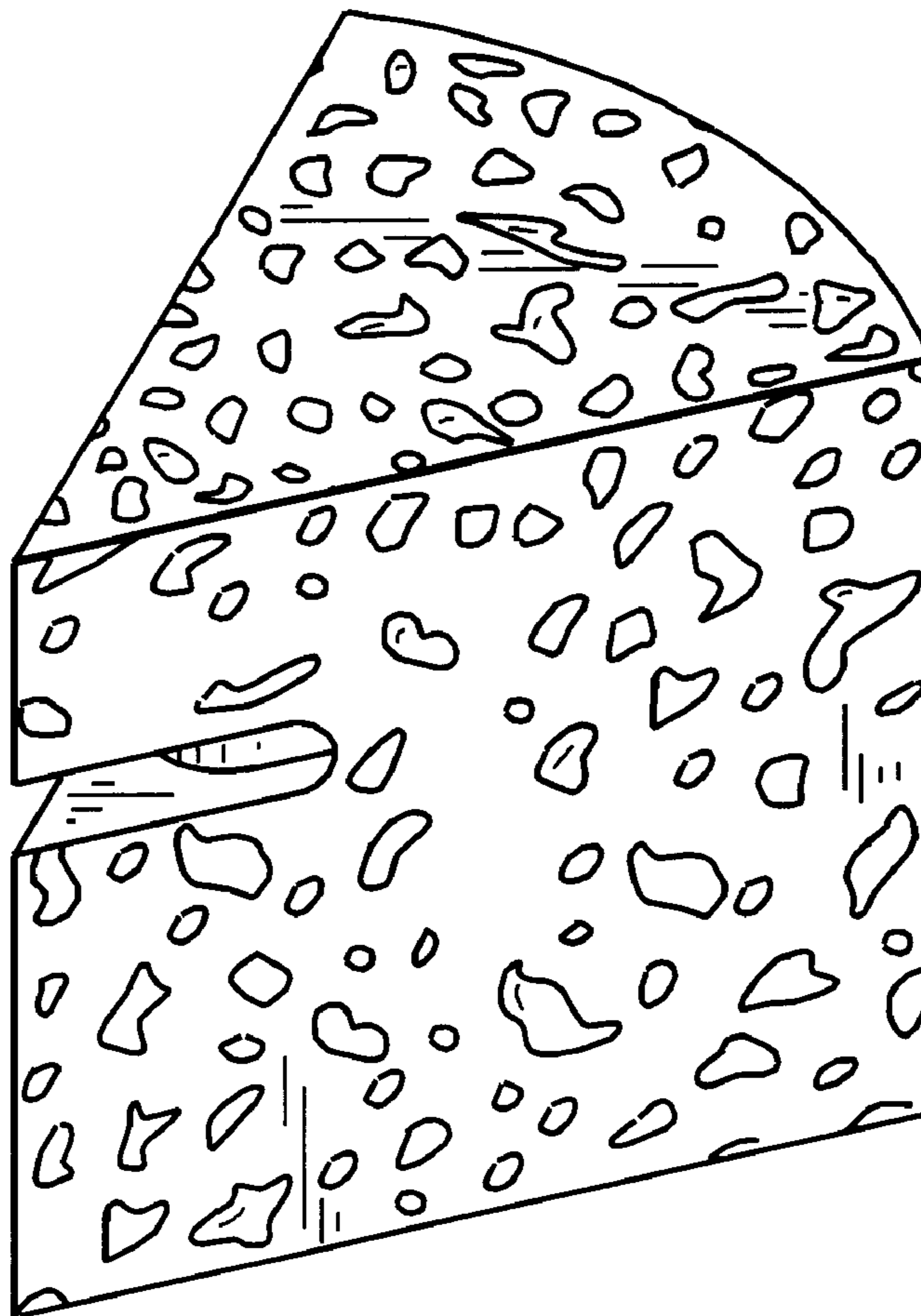
(57) **CLAIM**

The ornamental design for a novelty mask, as shown and described.

DESCRIPTION

FIG. 1 is an isometric view of a novelty mask in accordance with the present invention;
FIG. 2 is a front elevational view of the novelty mask of FIG. 1;
FIG. 3 is a side elevational view of the novelty mask of FIG. 1;
FIG. 4 is a top plan view of the novelty mask of FIG. 1; and,
FIG. 5 is a bottom plan view of the novelty mask of FIG. 1.

1 Claim, 1 Drawing Sheet



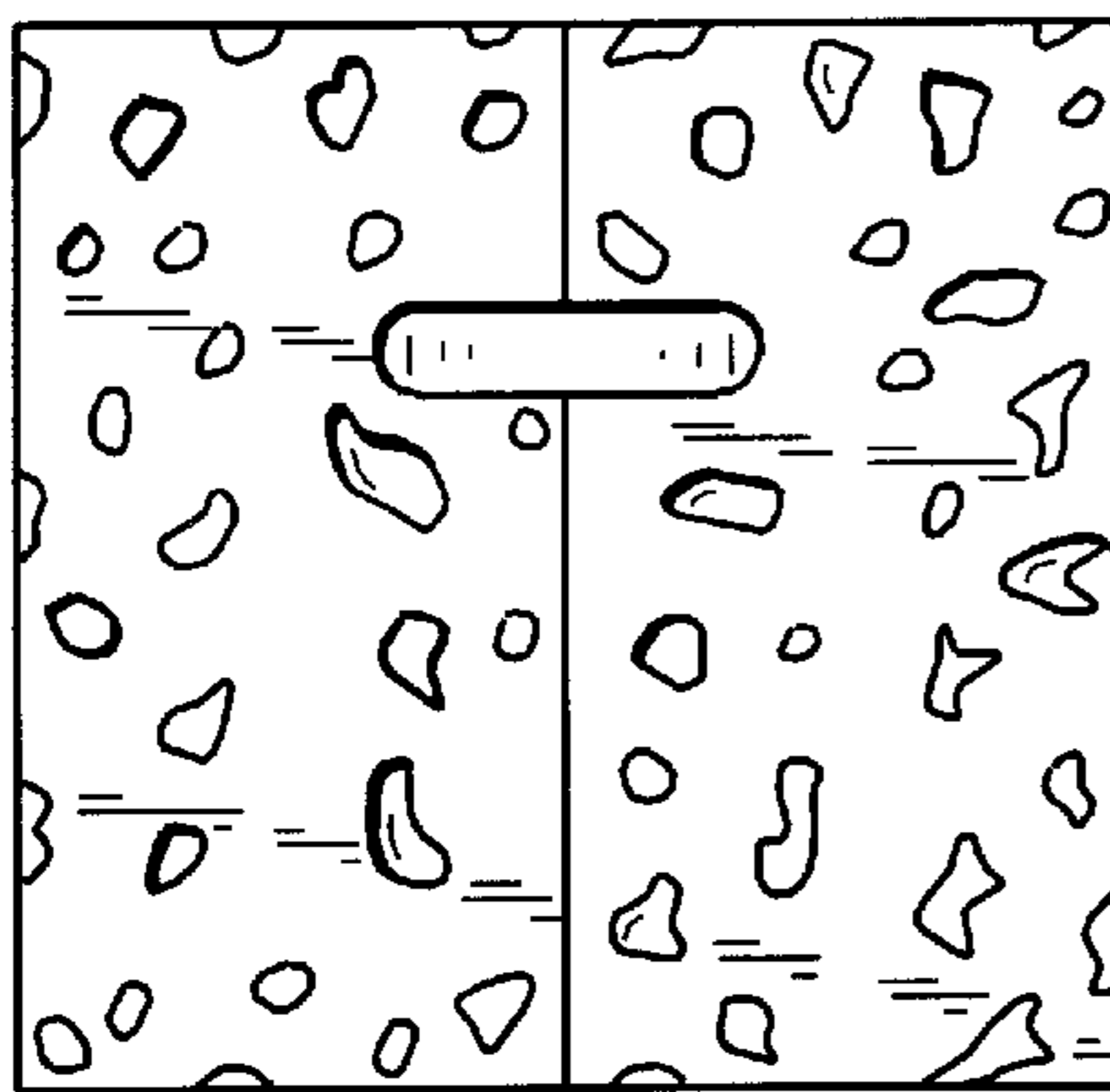
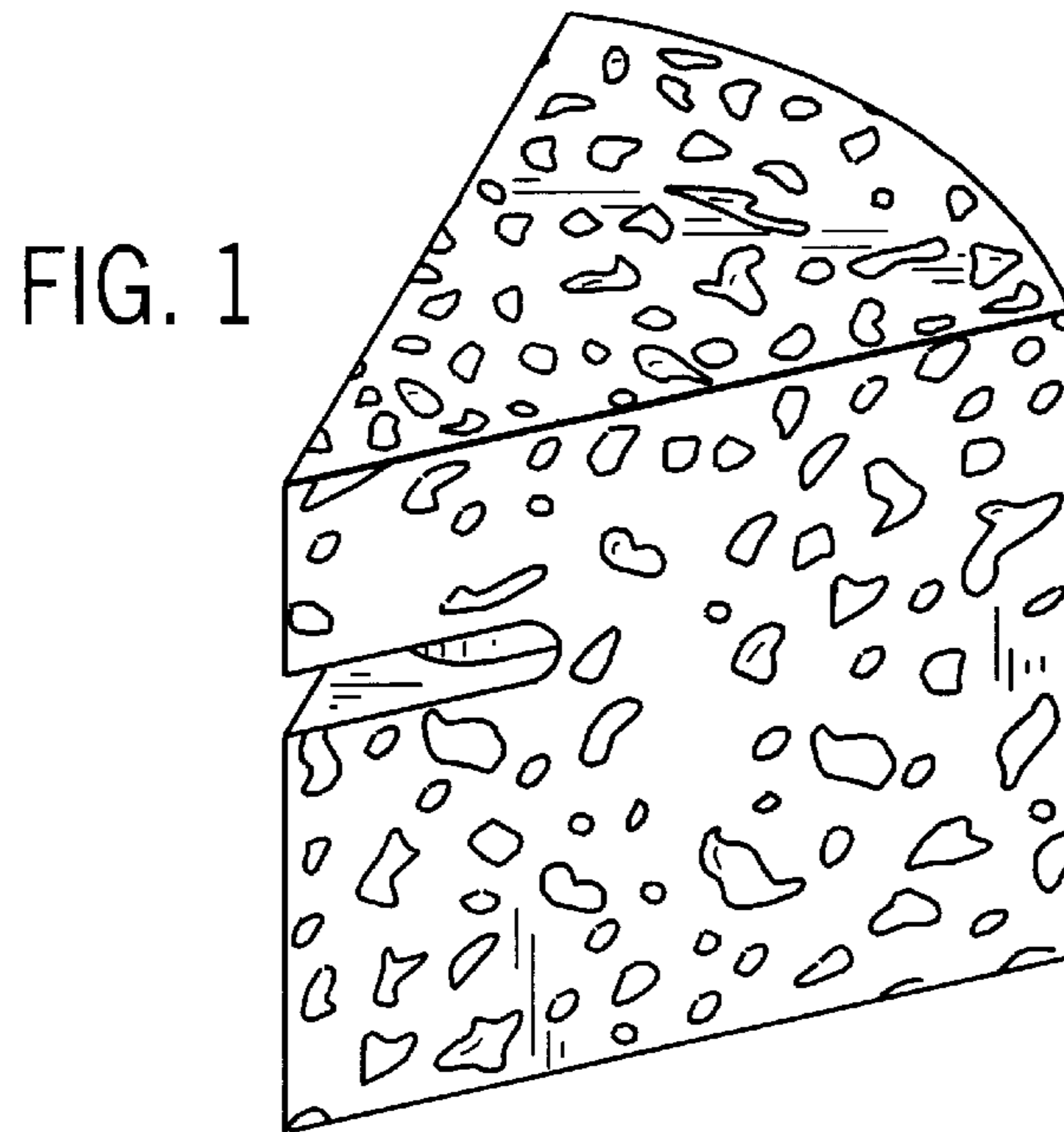


FIG. 2

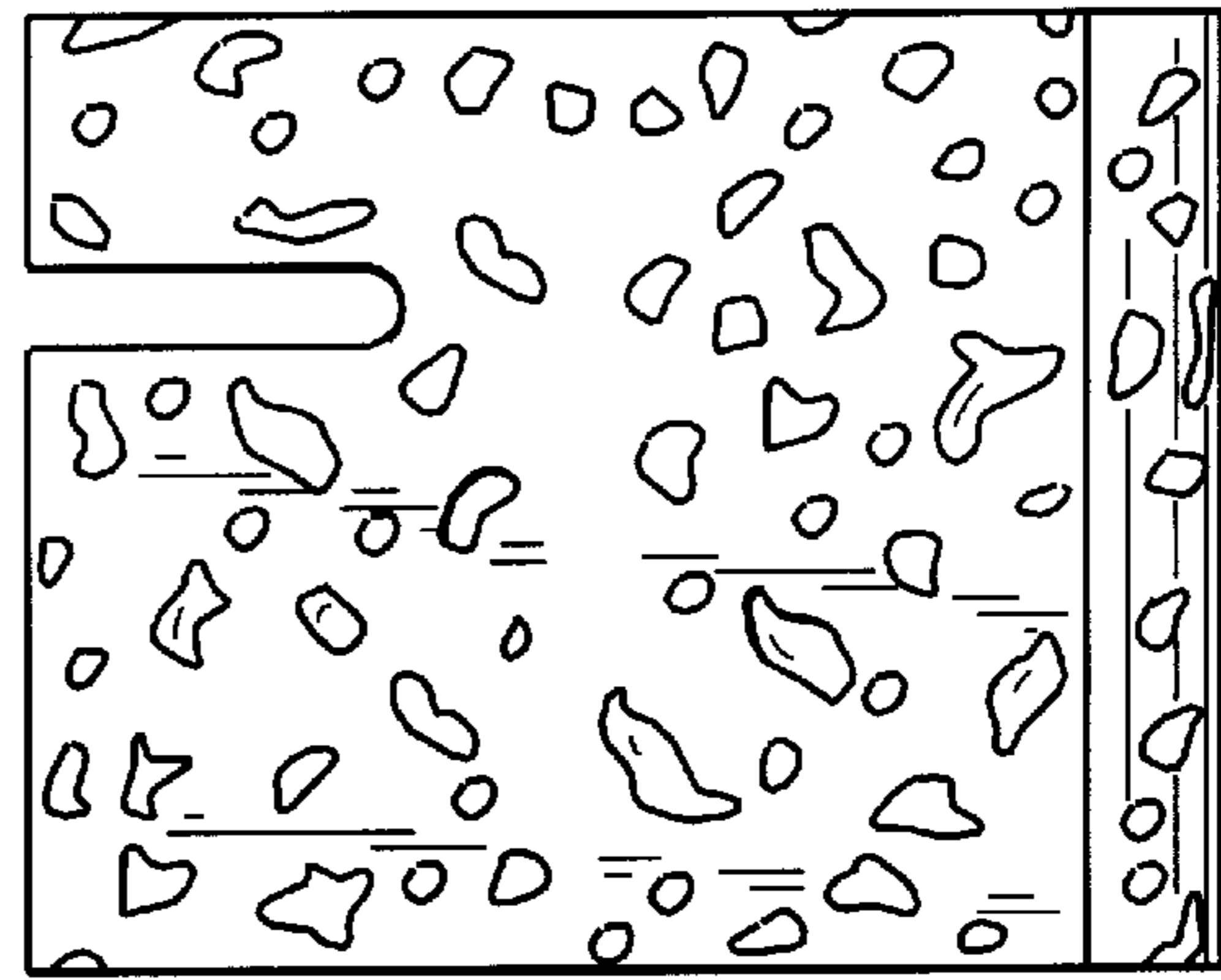


FIG. 3

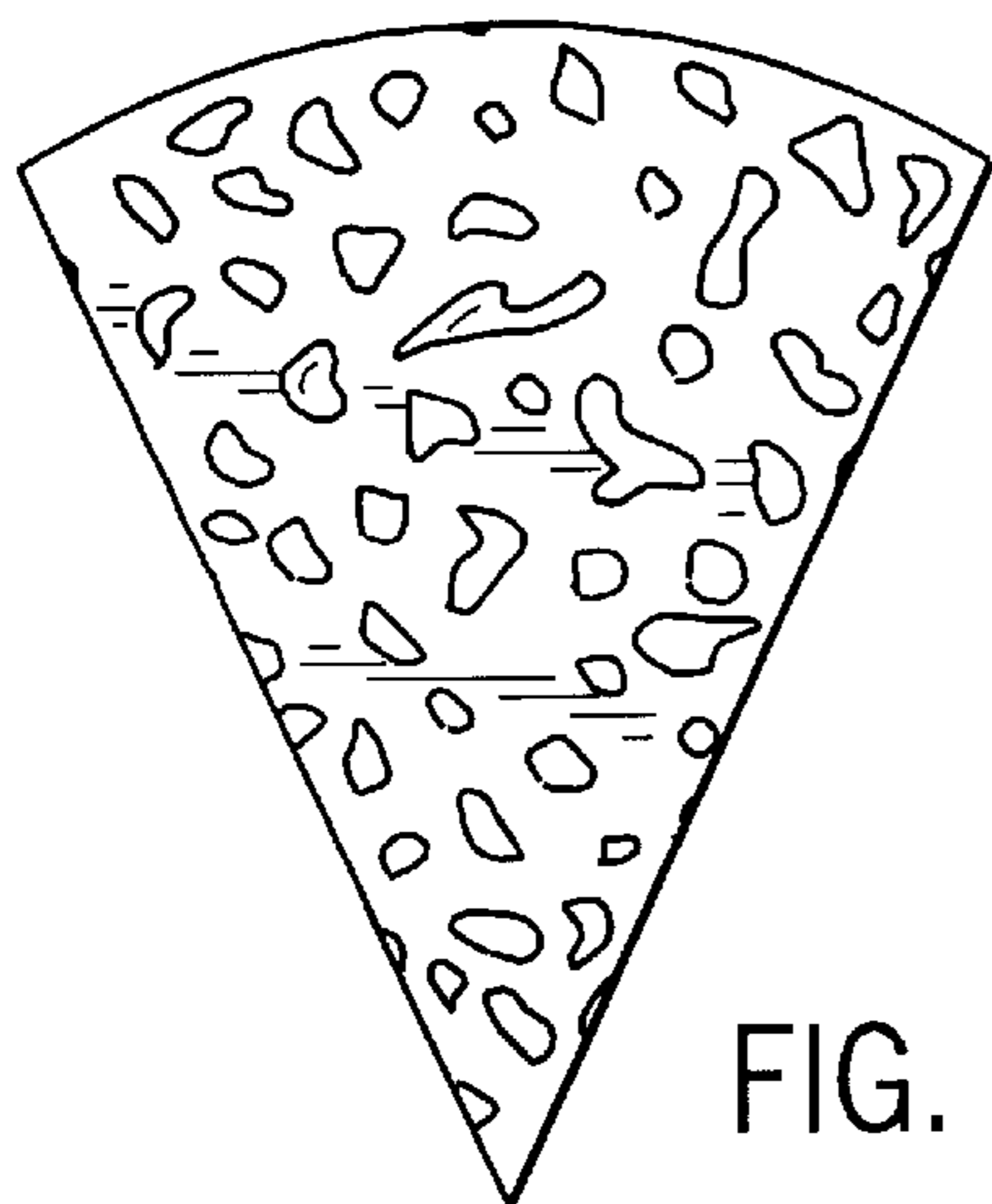


FIG. 4

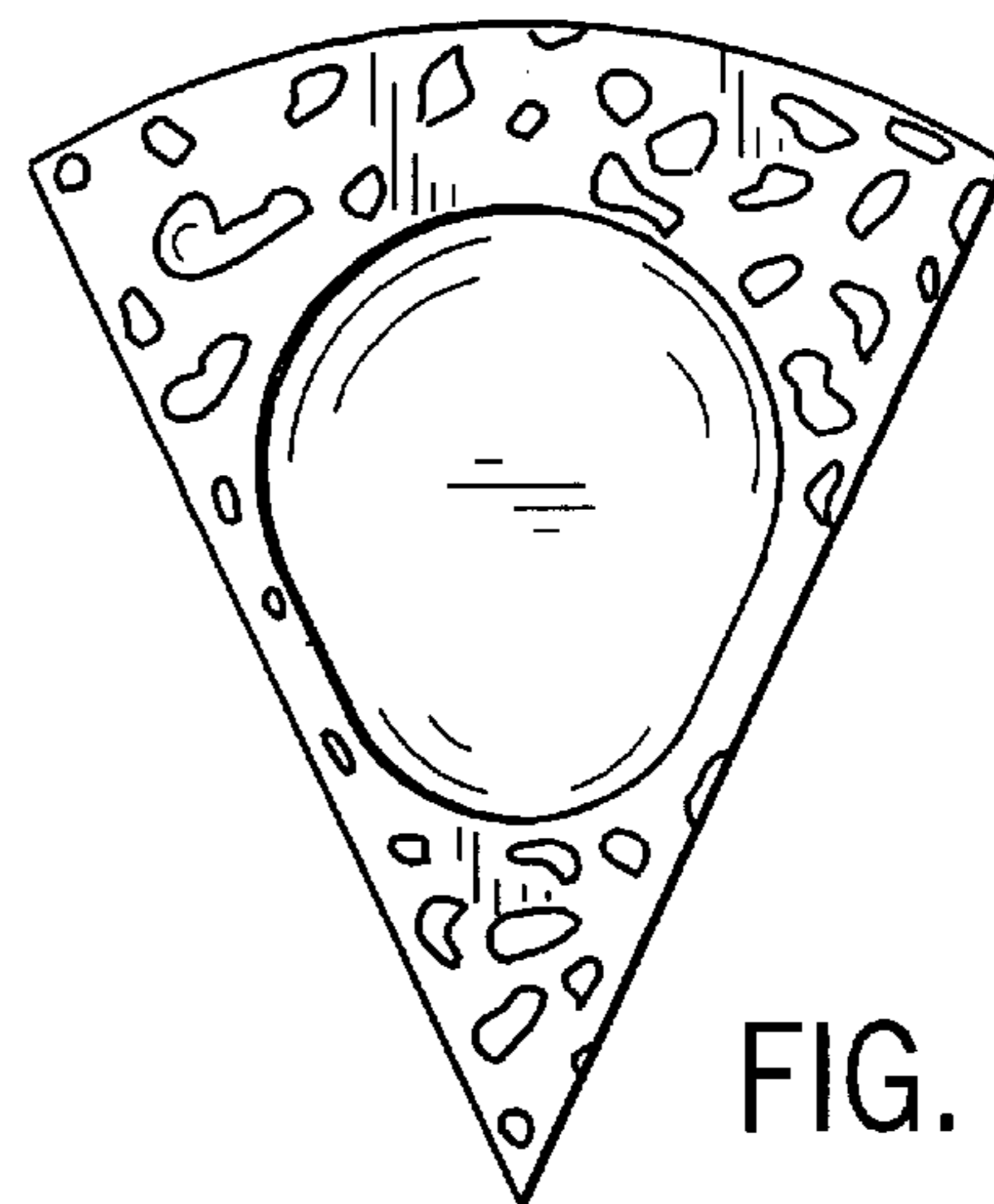


FIG. 5